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Four-dimensional ultrafast electron microscopy of phase transitions

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Reported here is direct imaging (and diffraction) by using 4D ultrafast electron microscopy (UEM) with combined spatial and temporal resolutions. In the first phase of UEM, it was possible to obtain snapshot images by using timed, single-electron packets; each packet is free of space-charge effects. Here, we demonstrate the ability to obtain sequences of snapshots ("movies") with atomic-scale spatial resolution and ultrashort temporal resolution. Specifically, it is shown that ultrafast metal-insulator phase transitions can be studied with these achieved spatial and temporal resolutions. The diffraction (atomic scale) and images (nanometer scale) we obtained manifest the structural phase transition with its characteristic hysteresis, and the time scale involved (100 fs) is now studied by directly monitoring coordinates of the atoms themselves.

imaging | diffraction | electron crystallography | vanadium dioxide

Electron microscopy has become a pivotal tool in numerous fields of study, from materials to biological imaging. In a previous publication (1), we introduced the concept of single-electron imaging for the development of 4D ultrafast electron microscopy (UEM). The potential of UEM was demonstrated by obtaining images and diffraction patterns of materials and biological cells (1), and the scope of future applications has been highlighted in recent commentaries and reviews (refs. 2 and 3; see also ref. 4 and references therein). Because single-electron packets have no significant space-charge broadening, images and diffraction patterns are observed with atomic-scale spatial resolution and with the time resolution being fundamentally determined by the ultrashort duration of the optical pulse introduced to generate the photoelectrons in the microscope.

The images and diffraction patterns reported (1) were "snapshots" at a particular point in time. However, as shown in Fig. 1, by delaying a second initiating optical pulse to arrive at the sample in the microscope with controlled time steps, it is possible to obtain a series of such snapshots with a well defined frame time. Unlike optical pump-probe experiments, this experimental task, for the microscope, is technically nontrivial for a number of reasons. To determine the zero time point, the clocking of the electron packet and optical pulse at the sample must be made with femtosecond time precision. Moreover, in contrast to these all-optical experiments, the cross-correlation between electron and photon pulses requires a new methodology. In addition, for 120-keV electrons, the group velocity of electron packets in the microscope is two-thirds the speed of light, and care has to be taken to account for this group velocity mismatch. Overcoming these hurdles in conjunction with attaining high quality, nanometer-scale samples in the microscope provides the capability of observing the dynamical changes of systems in the far-from-equilibrium state with the combined resolutions mentioned above.

With the 4D UEM arrangement shown in Fig. 1, we demonstrate such studies of imaging and diffraction for the metal-insulator phase transition in vanadium dioxide (VO_2). Based on the difference in conductivity the transition is termed metal-insulator, but when considering other properties it is referred to as a metal-semiconductor transition. The dioxide exhibits an

ultrafast transition and is an archetypical candidate for UEM study. Moreover, it is a strongly correlated system, and the interplay of electron correlations and nuclear motion is critical to the global dynamics of the phase transition. The material VO_2 undergoes a first-order phase transition from a low-temperature monoclinic (M) phase to a high-temperature tetragonal rutile (R) phase at $\approx 67^\circ\text{C}$ (5, 6). Since its discovery almost half a century ago, this phase transition has been the subject of intense study (6–8).

A widely accepted picture of the energy band diagram of the electronic structure was presented early by Goodenough (9) and is based on an orbital description. In the monoclinic phase (space group $P2_1/c$), the formation of V–V pairs and the tilting of these dimers with respect to the rutile c axis completely destroys the symmetry of the VO_6 octahedron, which results in the splitting of the $d_{||}$ manifold into a lower-energy, filled bonding ($3d_{||}$) and higher-energy, empty antibonding ($3d_{||}^*$) state. The antibonding π^* orbitals are pushed higher in energy because of the antiferroelectric tilting of the V dimers, which increases the overlap with the O 2p states. As a result, a band gap emerges, and a single 3d electron of V occupies the bonding $d_{||}$ combination (9). In the rutile phase (space group $P4_2/mnm$), VO_6 octahedra form an edge-sharing chain along the c axis. The important feature here is the degeneracy of the $3d_{||}$ states and the lowering of the π^* orbitals to be partly filled below the Fermi level.

There are a number of issues that remain unclear and require direct knowledge of structural dynamics. One issue is the exact nature of the energy gap, Peierls (9–11), or Mott–Hubbard (12, 13) type; in other words, the role of electron correlations must be elucidated in the description of the band structure. The actual electron–nuclear forces responsible for the change of structure from one phase to another must account for the ultrafast transformation. Recent studies considered both electron correlations within the V–V pairs and structural effects and successfully reproduced experimental data of photoemission and near-edge x-ray absorption fine structure spectra (14, 15). The phase transition is described as a correlation-assisted Peierls transition. In other words, the M phase can be described as a renormalized Peierls insulator at low energies and a Mott–Hubbard insulator at high energy (14).

Results and Discussion

Fig. 2 shows UEM real-space images obtained for the two phases of the transition: metallic (R) and insulator (M). With the microscope operating in the selected-area electron diffraction mode, we acquired the patterns in Fig. 3 before and after the transition. These images and diffraction patterns were obtained when the VO_2 films were driven through the transition by the heat deposited from the ramped, initiating (near infrared) laser

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Abbreviation: UEM, ultrafast electron microscopy; M, monoclinic; R, rutile.

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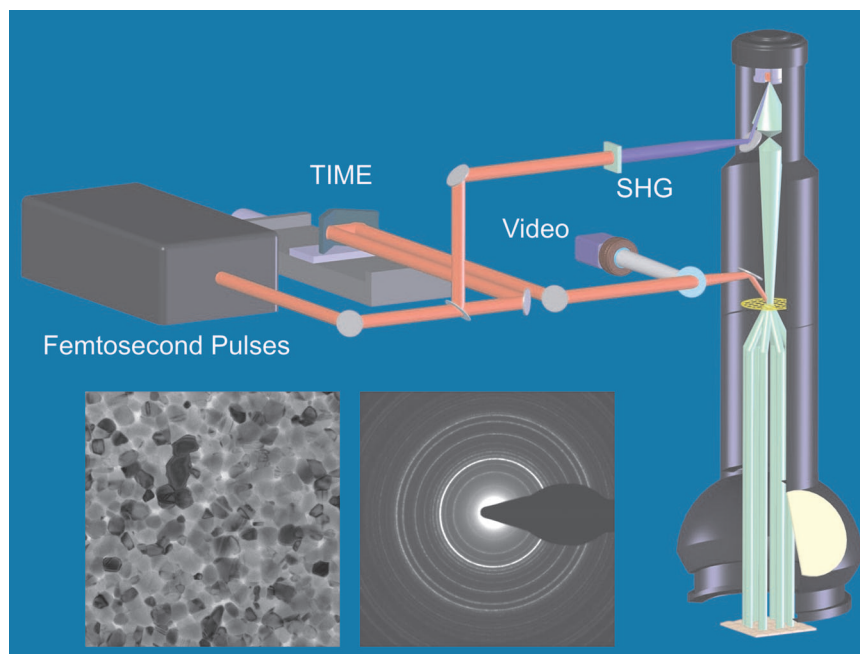


Fig. 1. A schematic of UEM at California Institute of Technology. Shown are the femtosecond laser system and the transmission electron column. The temporal resolution is determined by the time between the single-electron packets and the initiating heat or excitation pulses. Typical images (real space) and diffraction patterns obtained by UEM are also shown (for details see the text).

pulses at 776 nm. Equivalently, we obtained the same images and patterns in UEM by ramping the sample temperature through the phase transition. This equivalence together with the observed hysteresis is shown in Figs. 4 and 5. Below we shall discuss these imaging and diffraction experiments as a function of time as the system undergoes the transition. The laser power required to induce the phase transition is a function of absorption and the ability of the sample to cool down between laser pulses. For the samples in the present study, an average power of ≈ 1 mW was sufficient to drive the transition. The thickness of these samples was estimated to be 50–200 nm from the observed polycrystalline grain sizes in the microscope (Fig. 2). The micrographs showed drastic changes when passing through the phase transition.

To quantify the structural changes with atomic-scale resolution, electron diffraction patterns were recorded while raising the sample temperature through the phase transition. Large changes in diffraction patterns were observed in the temperature

region of 55–70°C (Fig. 3). The M and R phase share most of their diffraction peaks, but the M phase has several distinct peaks because of the broken symmetry originating from cell doubling. In Figs. 3 and 4, we can assign all diffraction peaks to these structures. The theoretical diffraction patterns (Figs. 3 and 4) of the polycrystalline materials for the R and M structures were generated by considering the crystal symmetry; similar patterns were constructed with JCEP/PCED software (16). The agreement between the simulated and experimental diffraction patterns is satisfactory and provides conclusive evidence that the correct phase of VO_2 films was fabricated. The electron diffraction data also demonstrate a characteristic heating/cooling hysteresis of the phase transition similar to that shown in Fig. 5. The width of the hysteresis loop, $\approx 15^\circ\text{C}$, is close to that reported for other films of VO_2 (17).

In Fig. 4, we display phase changes in the diffraction as the power was ramped. We also studied these changes as a function

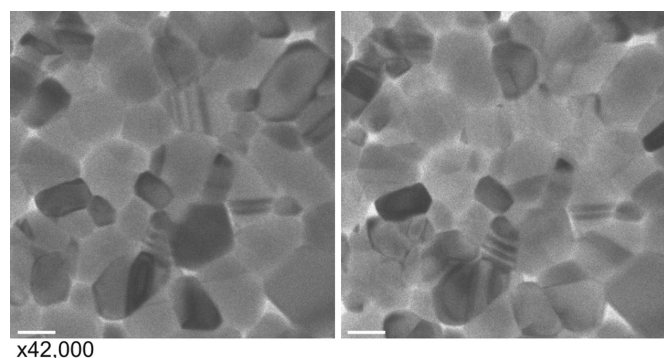


Fig. 2. UEM images obtained before the phase transition (Left) and after the phase transition (Right). The magnification is $\times 42,000$. (Scale bars: 100 nm.) It should be noted that these images would not be observed if the femtosecond pulses for photoelectron generation were blocked from the microscope.

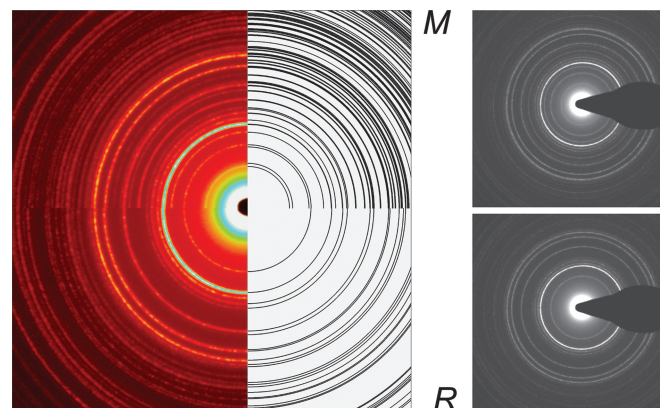


Fig. 3. UEM diffraction patterns. (Right) patterns obtained before and after the phase transition. (Left) The composite diffraction pattern of the two phases observed experimentally and assigned theoretically by the black rings. The analysis was done as described in the text.

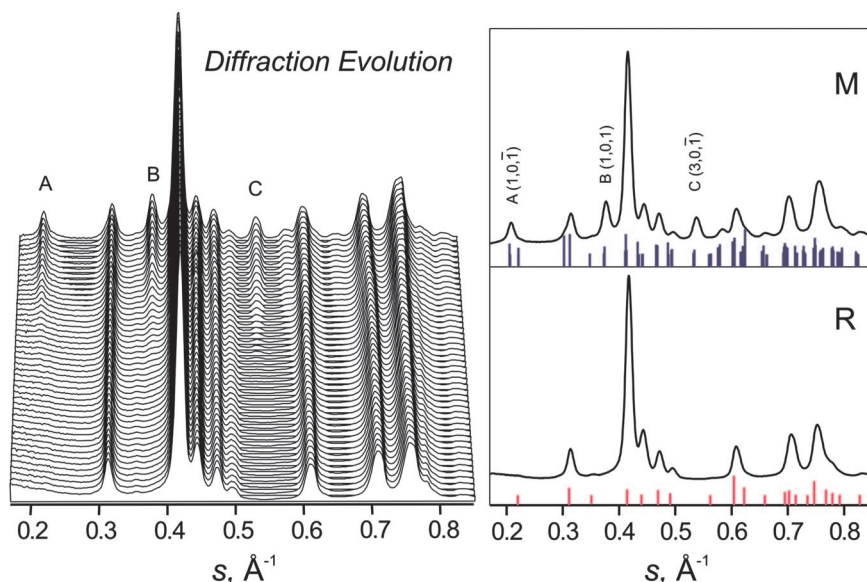


Fig. 4. Diffraction evolution through the phase transition. The evolution was observed by ramping either the temperature of the sample or the average power. Shown here are the characteristic changes in the diffraction peaks as the system undergoes the transition from the rutile structure to the monoclinic structure. (Left) Of particular interest are the peaks labeled A, B, and C, which characterize the monoclinic phase. (Right) The diffraction peaks together with the theoretical assignments indicated by the bars.

of increased temperature, and the behavior is similar. As shown below, the changes of diffraction peaks with time are indicative of this same phase change. Clearly, peaks A ($10\bar{1}$), B (101), and C ($30\bar{1}$) are characteristic of the monoclinic structure, and we focused our probing of structural dynamics on these peaks. For recording the temporal change, the electron and optical pulses were spatially and temporally coincident at the sample, and the time delay between them was controlled in steps of varying duration, 100 fs or longer. Knowing the transition temperature and shape of hysteresis (Fig. 5), instead of driving the entire phase transition with a single laser pulse, the average power was set such that the sample temperature was kept constant in the middle of the temperature range of the phase transition ($\approx 45^\circ\text{C}$); some crystallites were in the R phase, whereas others were in the M phase.

The frames were recorded in real time by continuously stepping the delay time between the electron and photon pulses. These frames were combined to make movies for images (Fig. 2) and diffraction (Fig. 3). The temporal behavior is presented in Fig. 6. Here, the integrated area, which is equivalent to the amplitude because the width remains constant, of the (30 $\bar{1}$) M diffraction peak is plotted against time. The transient response shows the increase in the fraction of the monoclinic structure while the average power during the scan was maintained at $\approx 45^\circ\text{C}$. We note that if we shift the average power to temperatures outside the transition region (e.g., 80°C or 20°C), we do not see the temporal change. From the best fit we obtained a characteristic transition time for the dynamics of 3.1 ± 0.1 ps. In contrast to the static diffraction patterns, where the diffraction peak diminishes as the system temperature was increased, here we observed the opposite effect.

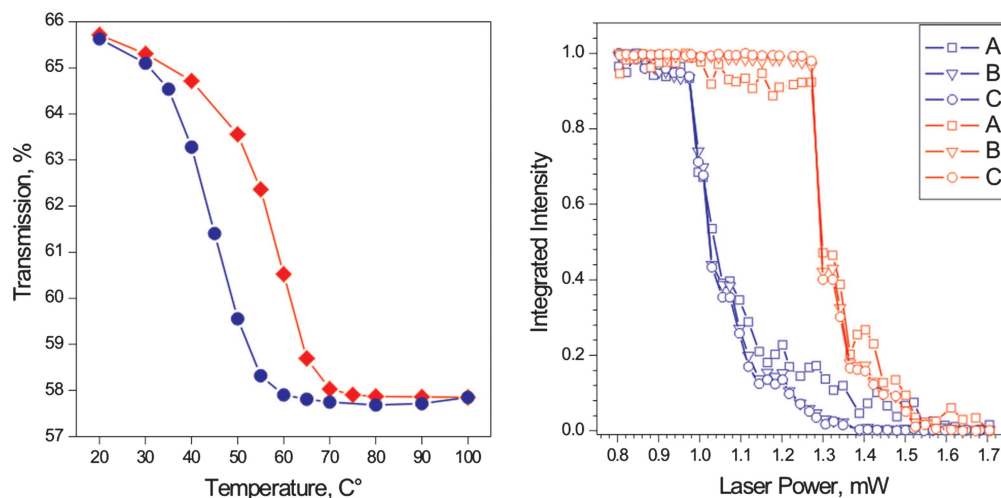


Fig. 5. Phase transition hysteresis. The reported behavior was from experiments varying the temperature of the sample at steady state (*Left*) and varying the average power (*Right*). The transmission was measured in a window between 1,300 and 1,400 nm. The phase transition occurs in the range of 55°C (forward ramp) and at ≈ 1.2 mW of average power. We note that, at a given temperature (e.g., 45°C), the structures allowed are determined by the vertical positions between blue and red curves.

